#### **ORIGINAL PAPER**



# Substitution effects on novel bicyclo[2.2.1]hepta-7-silylenes by DFT

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#### Abstract

Substitution effects on stability ( $\Delta E_{s-t}$ ) of novel singlet and triplet forms of bicyclo[2.2.1]hepta-7-silylenes are compared and contrasted, at B3LYP/6–311++G<sup>\*\*</sup> level of theory. All species appear as ground state minima on their energy surface, for showing no negative force constant. Singlets ( $1_s$ - $24_s$ ) are ground state and more stable than their corresponding triplets ( $1_r$ - $24_t$ ). The most stable scrutinized silylenes appear to be 2,3-disilabicyclo[2.2.1]hepta-7-silylene (9) for showing the highest value of  $\Delta E_{s-t}$ . This stability can be related to our imposed topology and  $\beta$ -silicon effect. The band gaps ( $\Delta E_{HOMO-LUMO}$ ) show the same trend as  $\Delta E_{s-t}$  and the lowest unoccupied molecular orbital energies. Also, the electrophilicity appears inverse correlation with our results of  $\Delta E_{s-t}$ . The purpose of the present work was to assess the influence of 1 to 6 silicon substitutions on the stability, band gaps, nucleophilicity, electrophilicity, and proton affinity. Finally, our investigation introduces novel silylenes with possible applications in chemistry such as semiconductors, cumulated multidentate ligands, etc.

Keywords Silylene · Stability · DFT · Divalent · Proton affinity

## Introduction

Sextet divalent silvlenes, with R<sub>1</sub>-Si-R<sub>2</sub> formula, are of great interest because of evolving from exotic reaction intermediates to important chemical species [1-5]. In contrast to the carbon atom, silvlenes have a low ability to form hybrid orbitals [4, 6-9] and therefore prefer the  $(ns)^2(np)^2$  valence electron configurations in their divalent species. Since two electrons remain as a singlet pair in the ns orbital, they mostly prefer to exist as singlets and can interact as a Lewis acid or base. Also, the simplest silvlene is SiH<sub>2</sub>, a singlet. The basicity of silvlenes may be triggered by their nucleophilicity or proton affinity [4, 10-12]. As a result, they can serve as ancillary ligands in transition metal complexes in which there are synergic electron transfers between the low valent silicon atoms and transition metals such as rhodium [13]. The first heavy alkene (DŠiCH (SiMe<sub>3</sub>)<sub>2</sub>) was reported in 1976 by Lappert [14]. Silylenes are applied in light-emitting diode (LED), electroluminescence (EL), silicon chemical vapor deposition (CVD) processes, photonics, optics, electronics, and semiconductor [15–23].

Electropositive Si atoms substitution can diminish  $\Delta E_{s-t}$  by lowering the energy of the triplet state [24–26]. Various investigations on silylenes with substituted electropositive atoms were reported [15, 27], such as Apeloig that studied the effects of electropositive substituents on  $\Delta E_{s-t}$  of silylenes [28–31].

Considering the applications of silylenes [15–23, 28], the purpose of the present work is to reach novel silylenes that accommodate up to six electropositive Si atoms at different possible positions (Table 1) and assess the influences of them on the geometrical parameters, stability ( $\Delta E_{s-t}$ ), the heat of hydrogenation ( $\Delta E_H$ ), nucleophilicity (*N*), and electrophilicity ( $\omega$ ), at B3LYP/6–311++G\*\* level of theory. Evidently, a number of them can be employed as multidentate ligands.

### **Computational methods**

Full geometry optimizations are accomplished without any symmetry constraints by means of hybrid functional B3LYP [32–35] and the standardized 6–311++G\*\* basis set, by using the GAMESS package of programs [32, 36]. Restricted and unrestricted B3LYP density functional methods are employed for singlet and triplet states, respectively.

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The nucleophilicity index, *N*, is defined as  $N = E_{\text{HOMO(Nu)}}$ - $E_{\text{HOMO(TCNE)}}$ , where TCNE is tetracyanoethylene and is chosen as the reference [37]. The global electrophilicity,  $\omega$  [38], is also calculated following the expression  $\omega = (\mu^2/2\eta)$ , where  $\mu$ is the chemical potential ( $\mu \approx (E_{HOMO} + E_{LUMO})/2$ ) and  $\eta$  is the chemical hardness ( $\eta = E_{LUMO} - E_{HOMO}$ ) [39] and natural bond orbital (NBO) charges are provided, at the same level of theory [32]. Structural parameters including bond distances, bond angles, dihedral angles, and symmetries are also calculated.

## **Results and discussion**

Silicon substitution effects on thermodynamic and structural parameters of bicyclo[2.2.1]hepta-7-silylenes are compared and contrasted, at B3LYP/6–311++G\*\* level of theory. Special consideration is paid to their singlet (s) and triplet (t) multiplicity, geometrical parameters, relative stability ( $\Delta E_{s-t} = E_t - E_s$ ), nucleophilicity (*N*), electrophilicity ( $\omega$ ), proton affinity ( $\Delta E_{PA}$ ), second-order perturbation stabilization energies ( $E^{(2)}$ ), and band gap ( $\Delta E_{HOMO-LUMO}$ ) (Tables 1, 2, 3, 4, 5, and 6). All structures appear with  $C_1$  symmetry, except silylenes 1, 4, 8, 16, 21, and 24 for showing  $C_2$  symmetries.

The silylene bond lengths (A- $\ddot{S}i$  or  $\ddot{S}i$ -D) for  $1_s$ - $24_s$  vs.  $1_t$ -24<sub>t</sub> vary in a range of 1.91 A to 2.50 A. Divalents with silicon adjacent to the silylene center have higher  $\ddot{S}i$ -Si bond lengths than  $\ddot{S}i$ -C. For instance, the  $\ddot{S}i$ -Si bond length in silylene  $2_s$  is 0.43 Å longer than  $\ddot{S}i$ -C. Interestingly, silylenes  $10_s$  and  $19_s$ have the lowest and highest bond lengths. Also, the bond lengths of singlet and triplet silylenes 8, 9, and 21 are similar (Table 1).

Divalent bond angles ( $\angle A\ddot{S}iD$ ) of our silylenes range from 71.62° to 102.08°. Silylene **4**<sub>s</sub> with high bond lengths (A-Si and Si-D = 2.48 Å) has the lowest  $\angle A\ddot{S}iD$  (71.62°), and **21**<sub>t</sub> with low bond lengths (A-Si and Si-D = 1.93 Å) has the highest  $\angle A\ddot{S}iD$  (102.08°). Triplet silylenes have wider divalent bond angles ( $\angle A\ddot{S}iD$ ) than their corresponding singlet states. For example, the  $\angle A\ddot{S}iD$  in silylene **6**<sub>t</sub> is 4.74° wider than divalent bond angles **6**<sub>s</sub>. Also, the bond angles ( $\angle \ddot{S}iDE$  and  $\angle \ddot{S}iAF$ ) of singlet silylenes are wider than corresponding triplets. For instance,  $\angle \ddot{S}iDE$  bond angles of **4**<sub>s</sub> and **4**<sub>t</sub> are 103.12° and 98.76°, respectively (Table 1).

The singlet-triplet energy gaps ( $\Delta E_{s-t}$ ) are employed to compare the relative stabilities at B3LYP/6–311++G\*\* levels of theory. The calculation of  $\Delta E_{s-t}$  in substitution of silicon atoms has been useful in providing insight into how the singlet

**Table 1** Optimized bond length (Å), bond angle ( $\angle A\ddot{S}id$ ,  $\angle \ddot{S}iDE$ , and  $\angle \ddot{S}iAF$  /deg), and symmetry for novel singlet ( $\mathbf{1}_s-\mathbf{24}_s$ ) and triplet ( $\mathbf{1}_{t}-\mathbf{24}_{t}$ ) silylenes, at B3LYP/6–311++G\*\* level

	E	F A C	<sup>B</sup> =		E B		
			Bond	length	Bo	nd angle (d	leg)
Structures	Silylenes	Symmetry	(Å	À)	DU	nd angle (d	icg)
			A-Ŝi	Β̈́ι-D	∠AŜiD	∠ŜiDE	∠ŜiAF
ŝi	<b>1</b> <i>s</i>	$C_2$	1.94	1.94	79.22	101.70	101.70
[]]	$1_t$	$C_2$	1.95	1.95	82.13	99.55	99.55
Si-Si-	$2_s$	$C_1$	2.40	1.97	75.19	108.09	94.20
<u> </u>	$2_t$	$C_1$	2.35	1.96	79.17	106.08	92.08
si	<b>3</b> <sub>s</sub>	$C_1$	1.92	1.95	83.30	102.89	103.70
SiH2							

Table 1	(continued)							
		$3_t$	$C_{I}$	1.93	1.95	86.90	98.76	99.79
	si	<b>4</b> <sub>s</sub>	$C_2$	2.48	2.48	71.62	103.12	99.04
		<b>4</b> <sub>t</sub>	$C_2$	2.36	2.36	78.95	98.72	97.71
	si si	$5_s$	$C_{I}$	2.39	1.97	80.05	110.44	97.03
	H SiH2	$5_t$	$C_1$	2.35	1.95	84.95	104.93	91.98
	si si	<b>6</b> <i>s</i>	$C_{l}$	2.42	1.93	78.51	110.26	95.57
	H Si H <sub>2</sub>	<b>6</b> <sub>t</sub>	$C_{I}$	2.36	1.94	83.25	105.97	91.26
	si	7 <sub>s</sub>	$C_{I}$	1.91	1.97	87.80	105.87	101.60
	H <sub>2</sub> Si SiH <sub>2</sub>	7 <sub>t</sub>	$C_{l}$	1.93	1.97	92.08	102.76	97.22
	H <sub>2</sub> Si	<b>8</b> <i>s</i>	$C_2$	1.94	1.94	88.04	105.81	101.18
	Z-Si H <sub>2</sub>	<b>8</b> <sub>t</sub>	$C_2$	1.94	1.94	92.23	104.16	96.35
	ši SiH2	<b>9</b> <sub>s</sub>	$C_1$	1.93	1.93	86.23	105.55	105.57
	Si Hi2	9 <sub>t</sub>	$C_{I}$	1.93	1.93	91.05	99.95	99.95
	si	10 <sub>s</sub>	$C_1$	1.91	2.50	81.42	98.89	107.92
	H <sub>2</sub> Si H	10 <sub>t</sub>	$C_{l}$	1.93	2.37	87.70	96.54	102.88
	Si-Si-SiL	11 <sub>s</sub>	$C_{I}$	2.41	1.93	82.06	111.92	97.76
	Si II2	11 <sub>t</sub>	$C_1$	2.35	1.94	87.98	105.16	91.92
	si	12 <sub>s</sub>	$C_{I}$	1.92	1.94	91.38	104.86	104.81
	H <sub>2</sub> Si SiH <sub>2</sub> H <sub>2</sub> Si	12 <sub>t</sub>	$C_{I}$	1.93	1.94	96.87	99.74	100.87
	si	13 <sub>s</sub>	$C_1$	2.39	1.97	85.94	110.83	92.47
	H <sub>2</sub> Si H SiH <sub>2</sub>	13 <sub>t</sub>	$C_{I}$	2.35	1.95	91.78	108.02	88.00

 Table 1
 (continued)

Si-Si-	14 <sub>s</sub>	$C_{I}$	2.42	1.94	83.87	107.78	100.33
H <sub>2</sub> Si	14 <sub>t</sub>	$C_{I}$	2.36	1.94	89.39	102.16	97.54
si	15 <sub>s</sub>	$C_1$	2.39	2.49	76.06	104.94	104.39
Sil-SiH2	15 <sub>t</sub>	$C_{I}$	2.35	2.36	83.27	98.55	97.10
ši si-	16 <sub>s</sub>	$C_2$	2.48	2.48	79.42	98.54	105.92
$H_2Si - Si$	16 <sub>t</sub>	$C_2$	2.36	2.36	88.18	93.02	103.99
Ši	17 <sub>s</sub>	$C_1$	2.37	2.51	80.71	105.59	100.34
H <sub>2</sub> Si H <sup>3</sup> SiH <sub>2</sub> H	17 <sub>t</sub>	$C_{I}$	2.35	2.37	88.72	102.53	93.95
Si H SiH <sub>2</sub>	18 <sub>s</sub>	$C_{I}$	2.40	2.41	79.43	103.92	108.67
H HI2	18 <sub>t</sub>	$C_{I}$	2.35	2.36	86.79	95.76	99.63
si Si	19 <sub>s</sub>	$C_{I}$	2.50	1.91	85.62	110.02	99.16
$II_2Si$ $Si_{II_2}$	19 <sub>t</sub>	$C_{I}$	2.37	1.93	92.96	103.27	96.83
Si H-Si-Si	<b>20</b> <sub>s</sub>	$C_{I}$	2.41	1.94	88.46	114.02	93.90
Si H2	20 <sub>t</sub>	$C_{I}$	2.36	1.94	95.28	109.24	87.55
Si U-Si-SiU-	<b>21</b> <i>s</i>	$C_2$	1.93	1.93	85.27	106.70	106.44
$H_2Si$ $Si$ $H_2$	21 <sub>t</sub>	$C_2$	1.93	1.93	102.08	101.57	101.44
Si H-Si-Si-Si	22 <sub>s</sub>	$C_{I}$	2.49	1.91	90.65	111.62	98.20
$H_2Si$ $H$ $SiH_3$ $H_2Si$ $H_2$	22 <sub>t</sub>	$C_1$	2.37	1.93	99.31	106.42	93.30
Si Hasi-Si-si	23 <sub>s</sub>	$C_1$	2.39	2.49	83.73	106.46	103.46
	23 <sub>t</sub>	$C_{I}$	2.35	2.36	92.81	102.96	93.71

Table 1	(continued)							
	si	24 <sub>s</sub>	$C_2$	2.41	2.41	88.33	103.64	106.71
I	$\begin{array}{c c} H_2Si & H \\ SiH_2 \\ I_2Si & H \\ H_2 \\ \end{array}$	24 <sub>t</sub>	$C_2$	2.36	2.36	97.84	99.26	99.42

is stabilized (or destabilized) relative to the triplet and also how the geometry of the two states is affected by substitution. All calculated  $\Delta E_{s-t}$  parameters appear with positive values indicating that every singlet silylene is more stable than its corresponding triplet state. For example, singlet  $2_s$  is 23.40 kcal/mol more stable than its corresponding triplet  $2_r$ . Evidently, among silylenes ( $1_s-24_s$ ), the most stable appears to be singlet  $9_s$  which is 39.75 kcal/mol more stable than its corresponding triplet  $9_r$ . The overall stability order of our silylenes based on their  $\Delta E_{s-t}$  values is 9 > 1 > 7 > 3 > 21 >12 > 8 > 2 > 6 > 10 > 5 > 11 > 19 > 22 > 20 > 14 > 4 > 15 >18 > 17 > 23 > 24 > 16 > 13 (Tables 2). This stability can be related to our imposed topology.

In the case of singlet silylene, we have  $\beta$ -silicon effect [40–43] that the maximum stabilization is a result of the interaction between the  $\beta$ -silicon and anti-bonding character of lone pair (LP<sup>\*</sup>) silylene that increases the electron population of silylene center. This effect is much smaller than the backdonating ability that must be related to both the greater polarizability of the C–Si electron density and to the ability of the C–Si bond to overlap effectively with the LP<sup>\*</sup> on the silylene center. So, silylenes **3**, **7**, **8**, **9**, **12**, and **21** with  $\beta$ -silicon and  $\sigma_{C-Si} \rightarrow LP^*{}_{Si}$  interactions have higher stability than others. Among them, every silylene that shows the higher level of  $E^{(2)}$  for  $\sigma_{C-Si} \rightarrow LP^*{}_{Si}$  interactions has higher stability than others. So, silylene **9** has the highest stability for two

<b>T     a</b> (0)   1 + + 1 +					
Table 2Singlet-tripletenergy gaps ( $\Delta E_{s-t}$ ,	Silylenes	$\Delta E_{\rm s-}$	Silylenes	$\Delta E_{s-}$	
kcal/mol) for singlet $(1_s - 1_s)$		t		t	
$24_s$ ) and triplet $(1_t-24_t)$ silylenes, at B3LYP/6–	$1_{s}, 1_{t}$	33.00	$13_s, 13_t$	12.39	
311++G** level of	$2_s, 2_t$	23.40	$14_s, 14_t$	19.43	
theory	$3_s, 3_t$	31.40	$15_s, 15_t$	16.50	
	$4_{s}, 4_{t}$	17.53	$16_s, 16_t$	13.44	
	$5_s, 5_t$	21.86	$17_s, 17_t$	16.02	
	$6_{s}, 6_{t}$	22.07	$18_s, 18_t$	16.45	
	$7_{s}, 7_{t}$	31.43	19 <sub>s</sub> , 19 <sub>t</sub>	20.44	
	$8_s, 8_t$	29.22	$20_s, 20_t$	20.10	
	$9_{s}, 9_{t}$	39.75	$21_s, 21_t$	30.53	
	$10_s, 10_t$	21.95	$22_s, 22_t$	20.33	
	$11_s, 11_t$	21.47	$23_s, 23_t$	14.50	
	$12_s, 12_t$	30.02	$24_s, 24_t$	14.46	

interactions ( $\sigma_{C(A)-Si(B)}$  and  $_{Si(C)-C(D)} \rightarrow LP^*{}_{Si}$ ) with the highest  $E^{(2)}$  (5.23 kcal/mol). Silylene 7 with two interactions ( $\sigma_{C(A)-Si(B)}$  and  $_{A(C)-Si(F)} \rightarrow LP^*{}_{Si}$ ,  $E^{(2)} = 4.36$  kcal/mol) has higher stability than 3 with one  $\sigma_{C(A)-Si(B)} \rightarrow LP^*{}_{Si}$  interaction ( $E^{(2)} = 5.16$  kcal/mol). In the same way, silylene 12 despite high  $E^{(2)}$  (3.52 kcal/mol) has lower stability than 21. Because, silylene 12 and 21 have three and four  $\sigma_{C(A)-Si(B)} \rightarrow LP^*{}_{Si}$  interactions, respectively (Table 3).

As the addition of silicon atoms, their stability decreased. For example, silylene 2 without any interactions has higher

**Table 3**Calculated second-order perturbation stabilization energies $(E^{(2)})$ , for the intermolecular interactions (donor/acceptor NBO) of singletsilylenes, at the B3LYP/6–311++G\*\* level of theory

Silylenes	Donor→acceptor	$E^{(2)}$ (kcal/mol)
1 <sub>s</sub>	-	-
$2_s$	-	-
$3_s$	$\sigma_{C(A)-Si(B)} \rightarrow LP^*_{Si}$	5.16
<b>4</b> <sub>s</sub>	-	-
$5_s$	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP^*_{\rm Si}$	4.25
<b>6</b> <i>s</i>	$\sigma_{C(D)-Si(C)} \rightarrow LP^*_{Si}$	4.85
$7_s$	$\sigma_{C(A)-Si(F) \text{ and } C(A)-Si(B)} \rightarrow LP^*_{Si}$	4.36
8 <sub>s</sub>	$\sigma_{C(D)-Si(C) \text{ and } C(A)-Si(F)} \rightarrow LP^*_{Si}$	3.35
9 <sub>s</sub>	$\sigma_{C(A)-Si(B) \text{ and } C(D)-Si(C)} \rightarrow LP^*_{Si}$	5.23
10 <sub>s</sub>	$\sigma_{C(A)-Si(B) \text{ and } C(A)-Si(F)} \rightarrow LP^* \ddot{S}_i$	4.20
11 <sub>s</sub>	$\sigma_{\rm Si(A)-Si(B)} \rightarrow \rm LP_{\ddot{S}i}^*$	3.35
12 <sub>s</sub>	$\sigma_{C(A)-Si(F)} \rightarrow LP^*_{Si}$	3.52
	$\sigma_{C(A)-Si(B)} \rightarrow LP^*_{Si}$	2.97
	$\sigma_{C(D)-Si(E)} \rightarrow LP^*_{Si}$	3.54
13 <sub>s</sub>	$\sigma_{Si(A)-Si(B) \text{ and } Si(A)-Si(F)} \rightarrow LP^*_{Si}$	1.24
14 <sub>s</sub>	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP^*_{Si}$	2.44
	$\sigma_{C(D)-Si(E)} \rightarrow LP^*_{Si}$	2.87
15 <sub>s</sub>	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP^*{}_{\rm Si}$	3.75
16 <sub>s</sub>	$\sigma_{Si(A)-Si(B) \text{ and } Si(D)-Si(E)} \rightarrow LP^* \ddot{S}i$	1.67
17 <sub>s</sub>	$\sigma_{Si(A)-Si(B) \text{ and } Si(A)-Si(F)} \rightarrow LP^*_{Si}$	2.68
18 <sub>s</sub>	$\sigma_{\rm Si(A)-Si(B)} \rightarrow \rm LP^*_{Si}$	4.47
	$\sigma_{\rm Si(C)-Si(D)} \rightarrow \rm LP^*_{Si}$	2.82
19 <sub>s</sub>	$\sigma_{\rm Si(C)-C(D)} \rightarrow LP^*_{\rm Si}$	4.61
	$\sigma_{C(D)-Si(E)} \rightarrow LP^*_{Si}$	3.12
20 <sub>s</sub>	$\sigma_{\rm Si(A)-Si(B)} \rightarrow \rm LP^*_{Si}$	2.45
	$\sigma_{C(D)-Si(C)} \rightarrow LP^*_{Si}$	4.20
21 <sub>s</sub>	$\sigma_{C(A)-Si(B) \text{ and } C(D)-Si(E)} \rightarrow LP^*_{Si}$	3.29
	$\sigma_{C(D)-Si(C) \text{ and } C(A)-Si(F)} \rightarrow LP^*_{Si}$	3.37
$22_s$	$\sigma_{Si(A)-Si(B) \text{ and } Si(A)-Si(F)} \rightarrow LP^*_{Si}$	1.29
	$\sigma_{C(D)-Si(E) \text{ and } Si(C)-C(D)} \rightarrow LP^*_{Si}$	3.57
$23_s$	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP^*_{Si}$	2.86
	$\sigma_{Si(D)-Si(C) \text{ and } Si(F)-Si(A)} \rightarrow LP^* \ddot{S}i$	1.49
24 <sub>s</sub>	$\sigma_{Si(A)-Si(B) \text{ and } Si(D)-Si(E)} \rightarrow LP^*_{Si}$	1.94
	$\sigma_{C(A)-Si(F) \text{ and } Si(C)-C(D)} \rightarrow LP^*\ddot{S}i$	1.47

gaps ( $\Delta L_{HO}$	MO-LUMO, KCal	/mor), nucleopi	innerty (IV), chennea		-2 + s, at D3L1	1/0-311++0	level of the	Лу	
Silylenes	E <sub>HOMO</sub>	$E_{\rm LUMO}$	$\Delta \mathrm{E}_{\mathrm{HOMO}-}$ lumo	N(eV)	$\omega ({\rm eV})$	$\mu$ (eV)	$\eta ({\rm eV})$	$\Delta E_{PA}{}^a$	ZPVE
1 <sub>s</sub>	-5.91	-2.49	78.67	3.55	2.58	-4.20	3.41	-216.20	91.94
2 <sub>s</sub>	-6.39	-2.93	79.95	3.06	3.13	-4.66	3.47	-222.65	86.26
3 <sub>s</sub>	-5.92	-2.59	77.00	3.53	2.71	-4.25	3.34	-219.79	84.63
<b>4</b> <sub><i>s</i></sub>	-6.07	-3.32	63.56	3.38	4.00	-4.69	2.76	-218.66	80.55
5 <sub>s</sub>	-5.85	-3.04	64.88	3.60	3.51	-4.44	2.81	-223.18	79.68
<b>6</b> <i>s</i>	-5.80	-2.98	65.20	3.64	3.42	-4.40	2.83	-224.87	79.13
$7_s$	-5.96	-2.63	76.85	3.49	2.77	-4.30	3.33	-221.05	77.72
<b>8</b> <sub>s</sub>	-5.93	-2.71	74.19	3.53	2.90	-4.32	3.22	-221.22	77.47
9 <sub>s</sub>	-5.98	-2.67	76.20	3.47	2.83	-4.33	3.30	-222.67	78.17
10 <sub>s</sub>	-5.81	-2.97	65.37	3.65	3.40	-4.39	2.83	-224.44	72.22
11 <sub>s</sub>	-5.90	-3.11	64.48	3.55	3.63	-4.50	2.80	-225.21	73.22
12 <sub>s</sub>	-6.01	-2.74	75.37	3.45	2.92	-4.37	3.27	-223.73	71.20
13 <sub>s</sub>	-5.91	-3.12	64.35	3.54	3.65	-4.51	2.79	-224.71	73.24
14 <sub>s</sub>	-5.81	-3.14	61.43	3.65	3.75	-4.47	2.66	-224.69	72.47
15 <sub>s</sub>	-6.07	-3.42	61.08	3.38	4.25	-4.75	2.66	-220.87	74.13
16 <sub>s</sub>	-6.04	-3.57	57.03	3.41	4.67	-4.80	2.47	-220.25	67.62
17 <sub>s</sub>	-6.07	-3.47	59.86	3.38	4.38	-4.77	2.60	-223.73	67.75
18 <sub>s</sub>	-6.16	-3.53	60.67	3.29	4.46	-4.84	2.63	-221.81	68.22
19 <sub>s</sub>	-5.87	-3.12	63.42	3.58	3.68	-4.50	2.75	-224.49	66.24
20 <sub>s</sub>	-5.92	-3.20	62.73	3.53	3.82	-4.56	2.72	-226.45	66.64
21 <sub>s</sub>	-6.08	-2.77	76.35	3.37	2.96	-4.43	3.31	-225.17	64.88
22 <sub>s</sub>	-5.98	-3.22	63.67	3.47	3.83	-4.60	2.76	-224.76	60.33
23 <sub>s</sub>	-6.13	-3.61	57.96	3.32	4.72	-4.87	2.51	-222.48	61.73
24 <sub>s</sub>	-6.17	-3.71	56.88	3.28	4.94	-4.94	2.47	-223.96	55.83

Table 4	The highest occupied and the lowest unoccupied molecular
orbital ene	ergies (E <sub>HOMO</sub> /eV, E <sub>LUMO</sub> /eV, respectively), along with band
gaps ( $\Delta E_I$	HOMO-LUMO, kcal/mol), nucleophilicity (N), chemical potential

( $\mu$ ), proton affinity ( $\Delta E_{PA}$ , kcal/mol), zero-point vibrational energy (ZPVE, kcal/mol), and global electrophilicity ( $\omega$ ) for singlet silylenes ( $1_s$ - $24_s$ ), at B3LYP/6–311++G\*\* level of theory

 $^a$  Based on the reaction:  $R_1R_2Si:$  +  $H^+ \rightarrow R_1R_2Si^+H$ 

Table 5NBO charges on -Si- for singlet  $(1_s-24_s)$  and triplet  $(1_t-24_t)$  silylenes, at B3LYP/6-311++G\*\* level of theory

Silylenes	Ši	Silylenes	Ši	Silylenes	Ši	Silylenes	Ši
1 <sub>s</sub>	1.001	1 <sub>t</sub>	0.7605	13 <sub>s</sub>	0.7207	13 <sub>t</sub>	0.4861
<b>2</b> <sub>s</sub>	0.6589	$2_t$	0.4195	14 <sub>s</sub>	0.7175	14 <sub>t</sub>	0.4643
<b>3</b> <sub>s</sub>	1.0168	$3_t$	0.7879	15 <sub>s</sub>	0.2966	15 <sub>t</sub>	0.0773
<b>4</b> <sub>s</sub>	0.2789	$4_{t}$	0.0592	16 <sub>s</sub>	0.3319	16 <sub>t</sub>	0.0866
5 <sub>s</sub>	0.6884	$5_t$	0.4531	17 <sub>s</sub>	0.3154	17 <sub>t</sub>	0.0967
6 <sub>s</sub>	0.6788	6 <sub>t</sub>	0.4418	18 <sub>s</sub>	0.3200	18 <sub>t</sub>	0.1082
7 <sub>s</sub>	1.0341	$7_t$	0.8085	19 <sub>s</sub>	0.7353	19 <sub>t</sub>	0.4937
<b>8</b> <sub>s</sub>	1.0449	8 <sub>t</sub>	0.8080	<b>20</b> <sub>s</sub>	0.7451	$20_{t}$	0.5075
9 <sub>s</sub>	1.0316	9 <sub>t</sub>	0.8352	<b>21</b> <sub>s</sub>	1.0857	$21_{t}$	0.8872
10 <sub>s</sub>	0.6938	10 <sub>t</sub>	0.4584	22 <sub>s</sub>	0.7774	$22_t$	0.5291
11 <sub>s</sub>	0.7056	11 <sub>t</sub>	0.4844	$23_s$	0.3529	$23_t$	0.1234
12 <sub>s</sub>	1.0608	12 <sub>t</sub>	0.8524	24 <sub>s</sub>	0.3827	$24_t$	0.1545

stability than **6** with  $\sigma_{C(D)-Si(C)} \rightarrow LP^*_{Si}$  interaction  $(E^{(2)} = 4.85 \text{ kcal/mol})$ . Likewise, silylene **19** with high interactions  $(\sigma_{Si(C)-C(D)} \rightarrow LP^*_{Si}, E^{(2)} = 4.61 \text{ kcal/mol})$  has lower stability than **11** with  $\sigma_{Si(A)-Si(B)} \rightarrow LP^*_{Si}$  interaction  $(E^{(2)} = 3.35 \text{ kcal/mol})$ . Silylene **10** with two interactions  $(\sigma_{C(A)-Si(B)} \text{ and } C(A)-Si(F) \rightarrow LP^*_{Si}, E^{(2)} = 4.20 \text{ kcal/mol})$  has higher stability then **5** with  $\sigma_{C(D)-Si(C)} \rightarrow LP^*_{Si}$  interaction  $(E^{(2)} = 4.85 \text{ kcal/mol})$  (Table 3).

In order to characterize the substituent effect on stability data, we have compared and contrasted the zero-point vibrational energy (ZPVE) of singlet silvlenes. Interestingly, the effect of successive divalent Si substituting on the calculated ZPVE shows the addition of silicon atoms decreases ZPVE. For example, silvlene **23**<sub>s</sub> with six silicon atoms has low stability ( $\Delta E_{s-t} = 14.50$  kcal/mol) and ZPVE (55.83 kcal/mol). Likewise, bicyclo[2.2.1]heptanylene (**1**<sub>s</sub>) without any silicon has high stability ( $\Delta E_{s-t}$  = 33.00 kcal/mol) and ZPVE (93.71 kcal/mol) (Table 4).

The correlation coefficients of the fit between the band gaps ( $\Delta E_{HOMO-LUMO}$ ) of our silylenes with  $\Delta E_{s-t}$  and  $E_{LOMO}$  are 0.78 and 0.84, respectively. For instance, silylene **9**<sub>s</sub> has high  $\Delta E_{s-t}$  (39.75 kcal/mol),  $\Delta E_{HOMO-LUMO}$  (76.20 kcal/mol), and  $E_{LOMO}$  (-2.67 eV) (Fig. 1 (a and b) and Table 4). Furthermore, the direct relationship between the  $\Delta E_{s-t}$  with  $\mu$  and  $\eta$  are demonstrated by the correlation coefficient of the linear fit between the two values ( $R^2 = 0.65$  and 0.77, respectively). For example, silylene **1**<sub>s</sub> has high stability ( $\Delta E_{s-t} = 33$  kcal/mol),  $\mu$  (-4.20 eV), and  $\eta$  (3.41 eV) (Fig. 1 (c and d)).

Also, the  $\omega$  appears inverse correlation with our results of  $\Delta E_{s-t}$  and  $\Delta E_{HOMO-LUMO}$  values ( $R^2 = 0.86$  and 0.78, respectively) (Fig. 1 (e and f)). The increasing electropositive or  $\pi$ -acceptor capability of the substituents decreases the

**Table 6** Calculated second-order perturbation stabilization energies  $(E^{(2)})$ , for the intermolecular interactions (donor/acceptor NBO) and bond angle (deg) of singlet  $(1'_s-24'_s)$  protonated silvlenes, at the B3LYP/6–311++G\*\* level of theory

		B C			
Protonated		E <sup>(2)</sup>	Bond an	gle (deg)	
silylenes	Donor→Acceptor	(kcal/mol)	∠SiDC	∠SiAB	
H <sub>Si</sub> @	$\sigma_{C(D)-C(C)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(A)-C(B)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(B)-C(C)} \rightarrow LP^{*}_{Si-H}$	9.93 10.34 3.66	91.62	91.26	
Bio Sio 2's	$\sigma_{C(D)-C(E)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{Si(A)-C(F)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(E)-C(F)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(D)-SiH} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(E)-H(exo)} \rightarrow LP^{*}_{Si-H}$	21.27 2.08 1.54 3.15 33.49	114.98	88.84	
Site Site	$\sigma_{C(D)-C(C)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{Si(A)-C(B)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(C)-Si(B)} \rightarrow LP^{*}_{Si-H}$	6.31 26.55 4.15	97.84	93.10	
H Si@ Si	$\sigma_{Si(A)-C(F) and C(D)-Si(C)} \rightarrow LP^*_{Si-H}$	1.52	103.12	99.04	

Table 6(continued)

<b>4</b> ′ <sub>s</sub>				
H Si⊕ H Si⊕ Si⊕ SiH₂ SiH₂	$\sigma_{C(D)-C(C)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{Si(A)-Si(B)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(C)-Si(B)} \rightarrow LP^{*}_{Si-H}$	5.63 21.45 3.27	101.11	81.13
$ \begin{array}{c} \overset{H_{i} \otimes}{\overset{H_{i} \otimes}}{\overset{H_{i} \otimes}{\overset{H_{i} \otimes}}{\overset{H_{i} \otimes}{\overset{H_{i} \otimes}}{\overset{H_{i} \otimes}{\overset{H_{i} \otimes}}{\overset{H_{i} \otimes}{\overset{H_{i} \otimes}}{\overset{H_{i} \otimes}}{\overset{H_{i} \otimes}}}}}}}}}}}}}}}}}}}}}}}}}}}}}}}}}}}$	$\sigma_{C(D)-C(C)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{Si(A)-C(B)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{Si(C)-C(B)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(D)-SiH} \rightarrow LP^{*}_{Si-H}$	31.82 1.80 1.15 1.30	94.08	94.24
H <sub>2</sub> Si H <sub>2</sub> Si 7's	$\sigma_{C(D)-C(C) \text{ and } C(D)-} \\ C(E) \rightarrow LP^*_{Si-H} \\ \sigma_{C(A)-Si(F) \text{ and } C(A)-} \\ Si(B) \rightarrow LP^*_{Si-H} \\ \sigma_{C(C)-Si(B) \text{ and } Si(F)-} \\ C(E) \rightarrow LP^*_{Si-H} $	1.95 9.78 1.43	101.56	98.29
$H_{2}Si = \frac{H_{1}}{Si \oplus}$	$\sigma_{C(D)-Si(C) \text{ and } C(A)-} Si(F) \rightarrow LP^* Si-H$ $\sigma_{C(D)-C(E) \text{ and } C(A)-} C(B) \rightarrow LP^* Si-H$ $\sigma_{Si(C)-C(B) \text{ and } Si(F)-} C(E) \rightarrow LP^* Si-H$	8.93 2.64 1.42	97.22	102.94
3	$\sigma_{C(D)-Si(C) \text{ and } C(A)-} Si(B) \rightarrow LP^*_{Si-H} \sigma_{Si(C)-Si(B)} \rightarrow LP^*_{Si-H}$	20.74 7.38	97.37	97.37
H <sub>2</sub> Si H <sub>2</sub> Si Si H 10's	$\sigma_{C(A)-Si(B)}$ and $C(A)-Si(F) \rightarrow LP^*Si-H$	8.58	92.17	104.43
$ \begin{array}{c} H\\ Si \oplus\\ H\\ Si \oplus\\ H_2\\ 11's \end{array} $	$\sigma_{C(D)-Si(C)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{Si(A)-Si(B)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{Si(C)-Si(B)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(D)-SiH} \rightarrow LP^{*}_{Si-H}$	28.13 6.16 3.33 1.15	97.48	91.10
H Si U12Si U12Si SiII2 U12Si	$\sigma_{C(A)-Si(B)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(A)-Si(F)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{Si(F)-Si(E)} \rightarrow LP^{*}_{Si-H}$ $\sigma_{C(D)-Si(E)} \rightarrow LP^{*}_{Si-H}$	2.50 15.86 6.36 15.90	105.79	100.88

Table 6	(continued)				
	H	<b>ب</b>			
	510	$\sigma_{C(D)-C(C)} \rightarrow LP_{Si-H}^{*}$	3.67		
	Si-Si-	$\sigma_{\rm Si(A)-Si(F)} \rightarrow LP_{si-H}^*$	2.79	102.60	82.91
	H <sub>2</sub> Sr H SH <sub>2</sub>	$\sigma_{C(C)-Si(B)} \rightarrow LP^*_{Si-H}$	2.18		
	1	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP^*_{\rm Si-H}$	14.35		
	<u>13's</u>				
	H Si⊕	I D*	22.51		
	\	$\sigma_{C(D)-Si(E)} \rightarrow LP_{Si-H}$	22.51		
	H SiH2	$\sigma_{Si(A)-Si(B)} \rightarrow LP_{Si-H}$	1.07	113.53	87.73
	HS	$\sigma_{Si(A)-C(F)} \rightarrow LP_{Si-H}$	5.01		
	14'	$\sigma_{\mathrm{C(F)-Si(E)}} \rightarrow \mathrm{LP}_{\mathrm{Si-H}}$	1./3		
	Si⊕	$\sigma_{\rm Si(D)-C(C)} \rightarrow LP^*_{\rm Si-H}$	2.89		
	Si	$\sigma_{\text{Si(A)-Si(B)}} \rightarrow LP^*_{\text{Si-H}}$	27.94	07 03	82.20
	H SiH2	$\sigma_{C(C)-Si(B)} \rightarrow LP^*_{Si-H}$	1.29	91.95	82.20
	Si/	$\sigma_{\text{Si}(A)-\text{Si}H} \rightarrow LP^*_{\text{Si}-H}$	1.33		
	15's	- 5I(A)-5III —- 5I-II			
	H				
		J.			
	-Si-SiH-	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP_{\star}^{*}_{\rm Si-H}$	4.65	100.89	86.55
	H Jung	$\sigma_{\rm Si(D)-Si(E)} \rightarrow LP^*_{\rm Si-H}$	4.65		
	H <sub>2</sub> Si H				
	<u> </u>				
	H Si⊕	- <b>-</b> *	4.04		
		$\sigma_{\rm Si(D)-C(C)} \rightarrow LP_{\rm Si-H}$	1.81		
	H-Si - Si - SiH,	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP_{\rm Si-H}$	53.63	98.29	75.07
	-si-	$\sigma_{C(C)-Si(B)} \rightarrow LP_{Si-H}$	1.49		
	Ĥ	$\sigma_{\rm Si(A)-SiH} \rightarrow LP_{\rm Si-H}$	2.56		
	$17'_s$				
	Sim	*			
	-si-	$\sigma_{\rm Si(D)-Si(C)} \rightarrow LP_{\rm si-H}^{*}$	7.43	02.07	00.07
	II Suit2	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP_{*Si-H}$	14.27	93.97	89.96
	H Si H H	$\sigma_{\rm Si(C)-Si(B)} \rightarrow LP_{\rm Si-H}$	1.88		
	18's				
	H	*			
	310	$\sigma_{C(D)-Si(C)} \rightarrow LP_{Si-H}$	11.87		
	H Sill2	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP_{\rm Si-H}$	2.69	104.71	90.59
	H <sub>2</sub> Si Si	$\sigma_{\rm Si(C)-Si(B)} \rightarrow LP_{\rm Si-H}$	1.60		
	19'	$\sigma_{C(D)-Si(E)} \rightarrow LP_{Si-H}$	4.80		
	Sio	*			
	SiSi	$\sigma_{\rm Si(D)-Si(C)} \rightarrow LP_{*Si-H}$	20.25	08.00	96 07
	H <sub>2</sub> SI H SIH <sub>2</sub>	$\sigma_{\rm Si(A)-Si(B)} \rightarrow LP_{*Si-H}$	12.36	90.90	80.U/
	Si	$\sigma_{\rm Si(C)-Si(B)} \rightarrow LP^{-}_{\rm Si-H}$	6.34		
	20's				

(continued)

Table 6

$\begin{array}{c} H\\H_2Si\\H_2Si\\H_2\\Si\\Si\\H_2\\Si$	$\sigma_{C(D)-Si(C) \text{ and } C(A)-} Si(F) \rightarrow LP^*_{Si-H}$ $\sigma_{C(A)-Si(B) \text{ and } C(D)-} Si(E) \rightarrow LP^*_{Si-H}$ $\sigma_{Si(C)-Si(B) \text{ and } Si(E)-} Si(F) \rightarrow LP^*_{Si-H}$	7.78 7.51 2.82	102.64	102.97
$H_{2}Si - Si - Si - Si + SiH_{2}$ $H_{2}Si - Si - Si + SiH_{2}$ $H_{2}Si - Si + SiH_{2}$ $H_{2}Si - Si + SiH_{2}$ $H_{2}Si - Si + SiH_{2}$	$\sigma_{C(D)-Si(C) and C(D)-} Si(E) \rightarrow LP^* Si-H$ $\sigma_{Si(A)-Si(B) and Si(A)-} Si(F) \rightarrow LP^* Si-H$ $\sigma_{Si(C)-Si(B) and Si(F)-} Si(E) \rightarrow LP^* Si-H$	7.49 2.56 1.45	107.23	90.03
$\begin{array}{c} \underset{H_{2}Si}{\overset{Si}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\underset{H_{2}}{\overset{Si}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{2}}{\underset{H_{1}}{H_{H$	$\sigma_{\text{Si(D)-Si(C)}} \rightarrow LP^*_{\text{Si-H}}$ $\sigma_{\text{Si(A)-Si(B)}} \rightarrow LP^*_{\text{Si-H}}$ $\sigma_{\text{Si(C)-Si(B)}} \rightarrow LP^*_{\text{Si-H}}$ $\sigma_{\text{Si(A)-Si(F)}} \rightarrow LP^*_{\text{Si-H}}$	3.28 12.11 1.17 1.91	94.36	91.88
$\begin{array}{c} H\\ H_2Si \\ H_2S$	$\sigma_{Si(D)-Si(C) \text{ and } Si(D)-Si(F)}$ $\rightarrow LP^*_{Si-H}$ $\sigma_{Si(A)-Si(B) \text{ and } Si(D)-}_{Si(E)}$ $\sum_{Si(E)} LP^*_{Si-H}$	4.05 4.47	97.19	96.27

population of the Si  $3p_z$  orbital leading to a high positive electrostatic potential in the lone pair region yielding higher electrophilicity of the silicon atom, thereby increasing the stability of the triplet silylene and decreasing singlet-triplet gap [44, 45]. In other words,  $\mu$  is a measure of stability; therefore, as  $\mu$  becomes high negative, the structure becomes less stable and easy to get an electron. For instance, **24**<sub>s</sub> with the highest  $\mu$  (-4.94 eV) and  $\omega$  (4.94 eV) has low stability ( $\Delta E_{s-t} =$  14.46 kcal/mol) and band gap ( $\Delta E_{HOMO-LUMO} =$  56.88 kcal/mol). On the other extreme, **1**<sub>s</sub> with the lowest negative  $\mu$  (-54.29 eV) and  $\omega$  (2.58 eV) shows high stability ( $\Delta E_{s-t} =$  33.00 kcal/mol) and band gap ( $\Delta E_{HOMO-LUMO} =$  78.87 kcal/mol) (Tables 2 and 4).

The nucleophilicity index and gas-phase proton affinity (PA) are critical factors for showing the aptitude of our silylenes for coordination to transition metal complexes. As a result, silylene  $12_s$  with rather high stability ( $\Delta E_{s-t} = 30.02 \text{ kcal/mol}$ ) and N (3.45 eV) has high negative  $\Delta E_{PA}$  (-223.73 kcal/mol) that can be applied as accumulated multidentate ligands (Tables 2 and 4).

The electrostatic potential (ESP) map has largely been used as a molecular descriptor of the chemical reactivity, which takes part in both electrophilic and nucleophilic reactions. For investigating, the electrostatic potential (ESP) surfaces are plotted over the optimized electronic structures of our silylenes using density functional B3LYP method with 6–311++G\*\* basis set. The red and blue regions indicate the lowest (most negative) and highest (most positive) electrostatic potential energy values, respectively (Fig. 2) [46]. The ESP maps show that silylene center with red region has the negative potential as a nucleophilicity site.

The NBO charges on  $-\ddot{S}i$ - were computed for the singlet and triplet states of the silylene species (Table 5). Charges on all the triplet silylenes are less than those of their corresponding singlet species. For example, atomic charges on  $-\ddot{S}i$ - of  $2_s$ and  $2_t$  are +0.6589 and + 0.4195, receptively. Due to the rather higher electronegativity of carbon than silicon atom, it is anticipated to place a higher partial positive atomic charge on its adjacent silylene ( $-\ddot{S}i$ -). In the other words, silicon atoms in singlets tend to have their nonbonding electrons in the atomic orbitals with higher *s*-character. Consequently, electropositive substitutions ( $-\ddot{S}i$ -) transfer charge from their corresponding  $\ddot{S}i$ -A and  $\ddot{S}i$ -D bonding orbitals with higher *p*-character to the partially populated *s*-type orbital on the silicon atom. For



Fig. 1 Correlation diagrams between  $\Delta E_{HOMO-LUMO}$  (kcal/mol) and  $\Delta E_{s-t}$  (kcal/mol) (a),  $E_{LUMO}$  (eV) and  $\Delta E_{s-t}$  (kcal/mol) (b),  $\mu$  (eV) and  $\Delta E_{s-t}$  (kcal/mol) (c),  $\eta$  (eV), and  $\Delta E_{s-t}$  (kcal/mol) (d),  $\omega$  (eV) and  $\Delta E_{s-t}$  (kcal/mol) (d)

example,  $3_s$  with two carbons adjacent to its silvlene center has a more positive atomic charge on its  $-\ddot{S}i-(+1.0168)$  than  $2_s$  which has one nitrogen ( $-\ddot{S}i-=+0.6589$ ).

The gas-phase proton affinity (PA) is one of the most important thermodynamic properties that shows the importance of acid-base chemistry [47]. The  $\Delta E_{PA}$  of reactions for singlet silylenes is calculated, at B3LYP/6–311++G\*\* levels of theory. We have employed the NBO analysis to stress the roles of intermolecular orbital interactions through second-order perturbation theory. The NBO analysis provides significant

Fig. 2 The ESP maps of singlet  $(1_s-24_s)$  silylenes, at B3LYP/6–311++G\*\* level of theory



evidence for the nature of our protonated silylenes. Every interaction that stabilization of positive charge causes increased negative  $\Delta E_{PA}$ . In this regard, silylene **1**<sub>s</sub> without any silicon atom at its structure has the lowest  $\Delta E_{PA}$ (-216.20 kcal/mol). Silicon atoms at A and D situations have less effect on the stability of the positive center. For instance, silylene **3**<sub>s</sub> with one Si at B situation has higher  $\Delta E_{PA}$  than **4**<sub>s</sub> with two Si at A and D situations because protonated silylene **3**'<sub>s</sub> has higher  $\sigma_{(A)-(B)} \rightarrow LP^*_{Si-H}$  interaction (E<sup>(2)</sup> = 26.55 kcal/mol) than **4**'<sub>s</sub> ( $E^{(2)}$  = 0.76 kcal/mol).

Contrary to our anticipation, silylene  $2_s$  with one silicon at situation A has the rather high  $\Delta E_{PA}$  (-222.65 kcal/mol) because of high  $\sigma_{C(E)-H(exo)} \rightarrow LP^*_{Si-H}$  interactions (33.49 kcal/mol) at  $2'_s$  (Tables 4 and 6). The silicon atoms in the B situation are better than C for stabilizing the positive center of silylene. For example, silylene  $7_s$  has higher  $\Delta E_{PA}$  than 8<sub>s</sub> (-221.05 and -221.22 kcal/mol, respectively), because protonated silylene 7's has higher  $\sigma_{C(A)}$ - $_{Si(B)} \rightarrow LP^*_{Si-H}$  interaction ( $E^{(2)} = 9.78$  kcal/mol) than  $\sigma_{C(D)-Si(C)} \rightarrow LP^*_{Si-H}$  interaction ( $E^{(2)} = 8.93$  kcal/mol) of  $8'_s$ . The important factor for stability of protonated silylenes is their bond angles (∠SiDC and ∠SiAB). For instance, the protonated center of 17's has stabilized its positive charge by bending too much to one side ( $\angle SiAB = 75.07^{\circ}$ ), so it has the highest  $\sigma_{Si(A)-Si(B)} \rightarrow$  $LP^*_{Si-H}$  interactions ( $E^{(2)} = 53.63$  kcal/mol). Likewise, silvlenes  $11_s$  and  $20_s$  with high interactions and low bond angles ( $\angle$ SiDC and  $\angle$ SiAB) have the highest  $\Delta E_{PA}$ (-225.21 and - 226.45 kcal/mol, respectively) (Tables 4 and 6).

## Conclusions

In this research, we have studied thermodynamical and geometrical parameters of novel singlet (s) and triplet (t) forms of bicyclo[2.2.1]hepta-7-silylenes, all of which appear as minima on their potential energy surfaces at B3LYP/6–311++G\*\* level of theory. The 2,3-disilabicyclo[2.2.1]hepta-7-silylene (9) shows the highest stability indicated by its relatively high  $\Delta E_{s-t}$ . The overall trend of  $\Delta E_{s-t}$  is 9 > 1 > 7 > 3 > 21 > 12 >8 > 2 > 6 > 10 > 5 > 11 > 19 > 22 > 20 > 14 > 4 > 15 > 18 >17 > 23 > 24 > 16 > 13, which appears rather similar to the trend of  $\Delta E_{HOMO-LUMO}$  and  $E_{LOMO}$ . Silylenes 3, 7, 8, 9, 12, and 21 with  $\beta$ -silicon have higher stability for  $\sigma_{C-Si} \rightarrow LP^*_{Si}$ interactions than others. So, silylene 9 has the highest stability for two  $\sigma_{C(A)-Si(B)}$  and  $Si(C)-C(D) \rightarrow LP^*_{Si}$  interactions with the highest  $E^{(2)}$  (5.23 kcal/mol).

The electrophilicity ( $\omega$ ) appears inverse correlation with our results of  $\Delta E_{s-t}$  and  $\Delta E_{HOMO-LUMO}$  values ( $R^2 = 0.86$ and 0.78, respectively). Silylene **1**<sub>s</sub> has a high stability ( $\Delta E_{s-t} = 33.00 \text{ kcal/mol}$ ),  $\Delta E_{HOMO-LUMO}$  (78.67 kcal/mol),  $\eta$ (3.41), and NBO charge on -Si- (1.001) has low  $\Delta E_{PA}$ (-216.20 kcal/mol), negative  $\mu$  (-4.20 eV), and  $\omega$  (2.58 eV). The interactions of donor and acceptor NBOs give a detailed assessment of  $\Delta E_{PA}$  and geometrical features of our protonated silylenes. Contrary to our anticipation, 1silabicyclo[2.2.1]hepta-7-silylene (**2**<sub>s</sub>) with one silicon has the rather high  $\Delta E_{PA}$  (-222.65 kcal/mol) because of high  $\sigma_{C(E)-H(exo)} \rightarrow LP^*_{Si-H}$  interactions (33.49 kcal/mol) at protonated silylene **2**'<sub>s</sub>. Also, the 2,6-disilabicyclo[2.2.1]hepta-7silylene (**7**<sub>s</sub>) has higher  $\Delta E_{PA}$  than 3,6disilabicyclo[2.2.1]hepta-7-silylene (**8**<sub>s</sub>) (-221.05 and - 221.22 kcal/mol, respectively), because protonated silylene 7'<sub>s</sub> has higher  $\sigma_{C(A)-Si(B)} \rightarrow LP^*_{Si-H}$  interaction ( $E^{(2)} =$  9.78 kcal/mol) than  $\sigma_{C(D)-Si(C)} \rightarrow LP^*_{Si-H}$  interaction ( $E^{(2)} =$  8.93 kcal/mol) of **8**'<sub>s</sub>.

The nucleophilicity index and gas-phase proton affinity (PA) are crucial factors for showing the aptitude of our silylenes for coordination to transition metal complexes. As a result, we introduce silylene  $12_s$  with rather high stability ( $\Delta E_{s-t} = 30.02$  kcal/mol), N (3.45 eV), and negative  $\Delta E_{PA}$  (-223.73 kcal/mol) that can be applied as accumulated multidentate ligands.

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Availability of data and material Not applicable.

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#### Declaration

Conflict of interest There authors declare no competing interests.

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